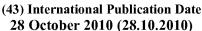
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(71) Applicant (for all designated States except US): WAKONDA TECHNOLOGIES, INC. [US/US]; 2a Gill Street, Woburn, MA 01801 (US).

(72) Inventors; and

- (75) Inventors/Applicants (for US only): LEITZ, Christopher [US/US]; 109 Spring Street, Watertown, MA 02472 (US). VINEIS, Christopher, J. [US/US]; 471 H Arsenal Street, Watertown, MA 02472 (US). FRITZEMEIER, Leslie, G. [US/US]; 82 Grant Street, Lexington, MA 02420 (US).
- (74) Agents: CURRIE, Matthew, T. et al.; Goodwin Procter LLP, Exchange Place, Boston, MA 02109 (US).
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A. CLASSI	IFICATION OF SUBJECT MATTER H01L31/0392				
	o International Patent Classification (IPC) or to both national class	sification and IPC	<del></del>		
	ocumentation searched (classification system followed by classi	ication symbols)			
H01L					
Documenta	tion searched other than minimum documentation to the extent t	nat such documents are included in	n the fields searched		
Electronic d	lata base consulted during the international search (name of dat	a base and, where practical, searc	h terms used)		
EPO-In	ternal				
C. DOCUM	ENTS CONSIDERED TO BE RELEVANT				
Category*	Citation of document, with indication, where appropriate, of th	e relevant passages	Relevant to claim No.		
X	US 2007/044832 A1 (FRITZEMEIER [US]) 1 March 2007 (2007-03-01 cited in the application paragraphs [0076] - [0077]; fig	)	1-27, 57-83		
X	US 5 282 902 A (MATSUYAMA JINS) 1 February 1994 (1994-02-01) column 13, line 15 - column 14 figure 7 column 26, line 44 - column 27	НО [JP]) , line 19;	73-83		
V	figure 13	·	,		
X	US 2008/217622 A1 (GOYAL AMIT   11 September 2008 (2008-09-11) paragraphs [0111], [0116], [0135], [0160]; figures 1,2,6	0134],	1-27, 57-83		
	<del></del>	-/			
X Furth	her documents are listed in the continuation of Box C.	X See patent family and	nex.		
"A" document defining the general state of the art which is not considered to be of particular relevance  "E" earlier document but published on or after the international filing date  "L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)  "O" document referring to an oral disclosure, use, exhibition or other means  "P" document published prior to the international filing date but		"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention "X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone "Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art.  "&" document member of the same patent family  Date of mailing of the international search report			
	4 October 2010	Date of mailing of the inte	mational search report		
Name and n	mailing address of the ISA/	Authorized officer			
	European Patent Office, P.B. 5818 Patentlaan 2 NL – 2280 HV Rijswijk Tel. (+31-70) 340-2040, Fax: (+31-70) 340-3016	Franche, Vi	incent		

# INTERNATIONAL SEARCH REPORT

International application No
PCT/US2010/032008

		PCT/US2010/032008					
C(Continuation). DOCUMENTS CONSIDERED TO BE RELEVANT							
Category*	Citation of document, with indication, where appropriate, of the relevant passages		Relevant to claim No.				
E	WO 2010/088366 A1 (WAKONDA TECHNOLOGIES INC [US]; FRITZEMEIER LESLIE G [US]; VINEIS CHRIS) 5 August 2010 (2010-08-05) the whole document		1-27, 57-83				
			1010				

# International application No. PCT/US2010/032008

## INTERNATIONAL SEARCH REPORT

Box No. II Observations where certain claims were found unsearchable (Continuation of item 2 of first sheet)
This international search report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:
Claims Nos.:     because they relate to subject matter not required to be searched by this Authority, namely:
2. Claims Nos.: because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically:
3. Claims Nos.: because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).
Box No. III Observations where unity of invention is lacking (Continuation of item 3 of first sheet)
This International Searching Authority found multiple inventions in this international application, as follows:
see additional sheet
1. As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.
2. As all searchable claims could be searched without effort justifying an additional fees, this Authority did not invite payment of additional fees.
3. As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:
A. No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:  1-27, 57-83
Demonstrate Destant
Remark on Protest  The additional search fees were accompanied by the applicant's protest and, where applicable, the payment of a protest fee.
The additional search fees were accompanied by the applicant's protest but the applicable protest fee was not paid within the time limit specified in the invitation.
No protest accompanied the payment of additional search fees.

## FURTHER INFORMATION CONTINUED FROM PCT/ISA/ 210

This International Searching Authority found multiple (groups of) inventions in this international application, as follows:

1. claims: 1-27, 57-83

A semiconductor structure and a method of manufacturing thereof, comprising a substrate, a semiconductor layer and a buffer layer there between.

2. claims: 28-42

A method for forming a semiconductor device, comprising an oxidation-resistant layer between the substrate and the semiconductor layer.

3. claims: 43-56

A method for forming a semiconductor device, comprising an etch-stop and a diffusion barrier layers between the substrate and the semiconductor layers.

4. claims: 84-100

A semiconductor structure comprising an oxide and a buffer layers between the semiconductor layer and the substrate.

5. claims: 101-104

A semiconductor structure comprising an etch-stop between a textured template and a substrate.

6. claims: 105-118

A semiconductor structure comprising a lift-off layer between the template and the substrate.

### **INTERNATIONAL SEARCH REPORT**

Information on patent family members

International application No PCT/US2010/032008

	Publication date	Patent family member(s)		Publication date	
A1	01-03-2007	NONE			
Α	01-02-1994	JP JP			21-06-1999 20-11-1992
<b>A</b> 1	11-09-2008	WO	2008112115	A1 ·	18-09-2008
A1	05-08-2010	US	2010193795	A1	05-08-2010
	A 1	A1 01-03-2007 A 01-02-1994 A1 11-09-2008	A1 01-03-2007 NONE A 01-02-1994 JP JP A1 11-09-2008 WO	A1 01-03-2007 NONE  A 01-02-1994 JP 2908067 JP 4334069  A1 11-09-2008 WO 2008112115	A1 01-03-2007 NONE  A 01-02-1994 JP 2908067 B2 JP 4334069 A  A1 11-09-2008 WO 2008112115 A1